

INFORMATION DISCLOSURE STATEMENT BY APPLICANT PTO FORM 1449		Art. Docket No. 10191/2262	Serial No. 10/070286 To Be Assigned
Applicant(s) Hubert BENZEL et al.			
Filing Date Herewith	7/8/02	Group	T Be Assigned 1765

U. S. PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NUMBER	PATENT DATE	NAME	CLASS	SUBCLASS	FILING DATE
<i>WMS</i>	5,725,785*	March 10, 1998	Ishida et al.			

*Copy of reference is not enclosed because reference is cited in Search Report (copy of reference provided by International Searching Authority).

FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB-CLASS	TRANSLATION	
						YES	NO
<i>WMS</i>	WO 98/53351*	Nov. 26, 1998	PCT				
	1 079 431*	Feb. 28, 2001	EP				
	0 867 921*	Sept. 30, 1998	EP				

*Copy of reference is not enclosed because reference is cited in Search Report (copy of reference provided by International Searching Authority).

OTHER DOCUMENTS

EXAMINER'S INITIALS		AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.
<i>WMS</i>		Rinke et al., "Quasi-Monocrystalline Silicon for Thin-Film Devices," Applied Physics A: Materials Science and Processing, Springer Verlag, Berlin, Federal Republic of Germany (June 1999)*

*Copy of reference is not enclosed because reference is cited in Search Report (copy of reference provided by International Searching Authority).

EXAMINER	<i>Anita Slawter</i>	DATE CONSIDERED	<i>6/27/04</i>
EXAMINER: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.			